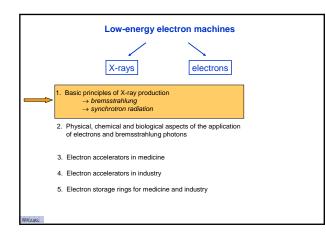
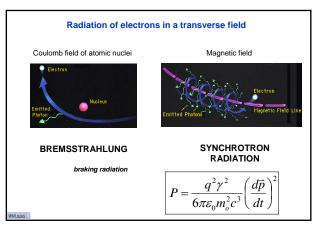
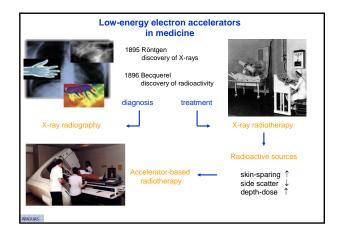
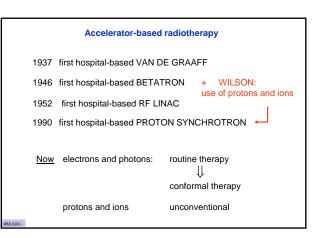


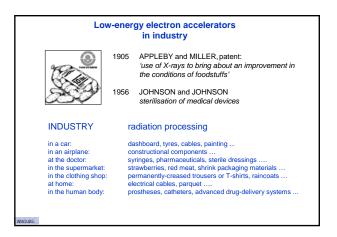
	APPLICATION				
Accelerators in the world year 2007 * (approximate numbers)	High-energy physics research				
	Synchrotron radiation sources		50		
	Ion beam analysis				
	Photon or electron therapy				
	Hadron therapy		30		
	Radioisotope production	550			
	Ion implantation		9500		
	Neutrons for industry or security		1000		
	Radiation processing		2000		
	Electron cutting and welding		4500		
	Non-destructive testing		650		
* R. Hamm at 9th ICFA Seminar October 30, 2008		TOTAL	27700		
WJUAS	~ 60% low-energy electron accelerators				

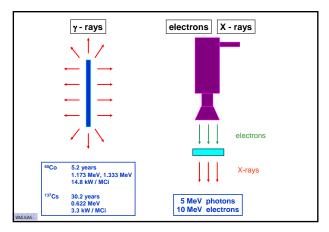


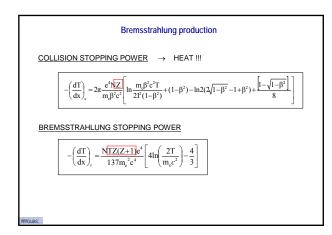


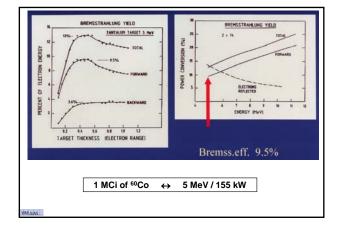


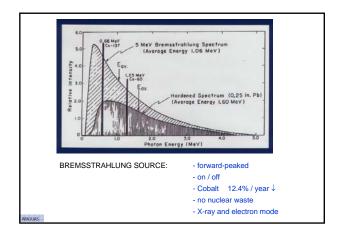


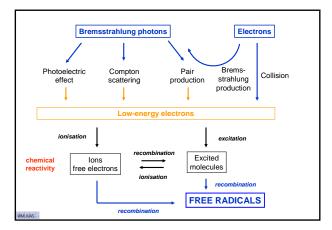


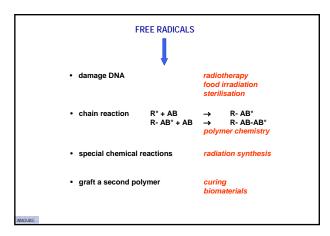


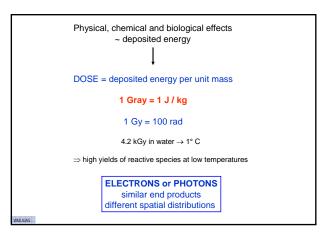


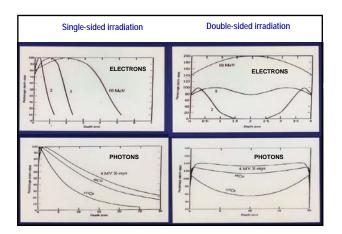


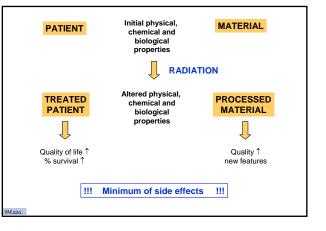


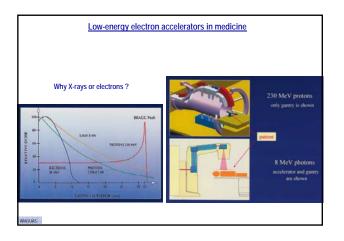


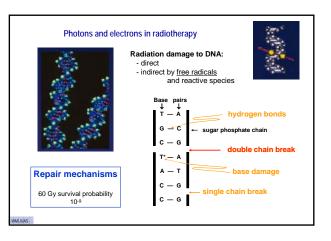


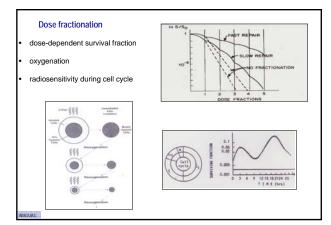


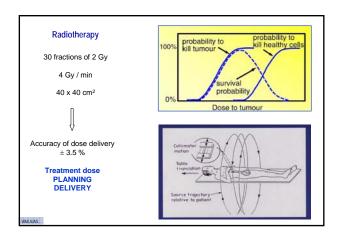


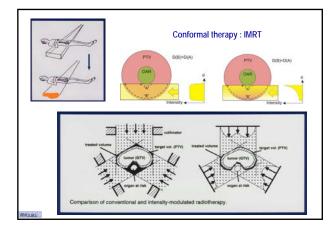


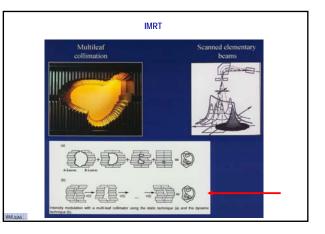












4 - 25 MeV 0.5 - 50 μA 1 - 4 Gy / min 5

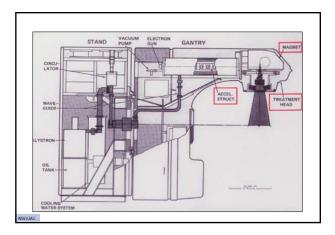
5 % over 40 x 40 cm²

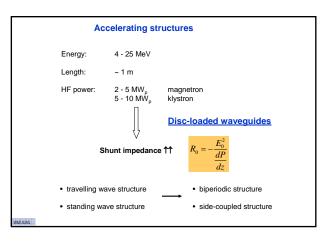
5 % over 25 x 25 cm² below 10⁻³ at 1 m 360° 1 mm

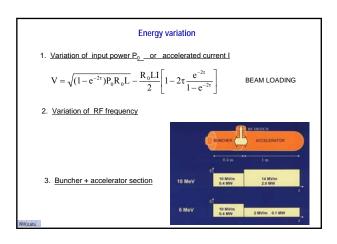
15 (rotation and translation) energy, position, direction 5 x 3 x 3 m³

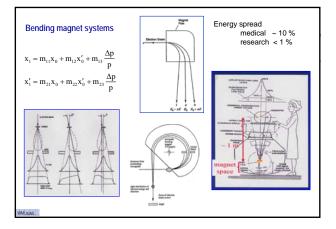
Radiation field requirements			Machine requirement	
BEAM • well defined • variable in size • moveable in three dimensions • variable energy • variable intensity	DOSE RATE • high • irradiation time ~ 1/2 minute • accurately monitored • fail-safe feedback to accelerator		 energy range intensity range dose rates number of electron energies number of X-ray energies homogeneity of X-ray fields 	4 - 2 0.5 - 1 - 4 5 2 5 %
X-ray ⇔ electron mode pure and well-confined <u>TREATMENT UNIT</u> reliable and reproducible easy maneuvrable simple and fail-safe very compact	DOSE DISTRIBUTION • uniform or • non-uniform in predefined way • controllable • stable	WWJUAS	 homogeneity of electron fields leakage doses gantry rotation isocentre definition degrees of freedom good definition at target volume 	5 % belo 360 1 m 15 (ene 5 x

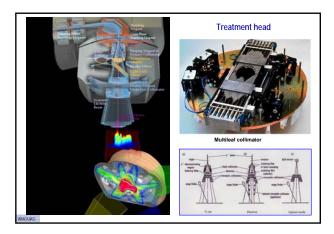
4

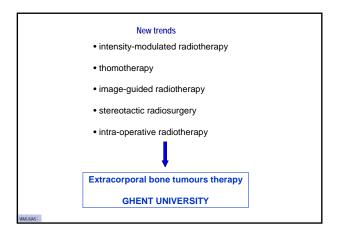


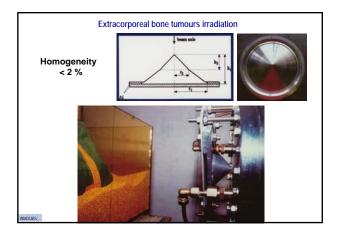


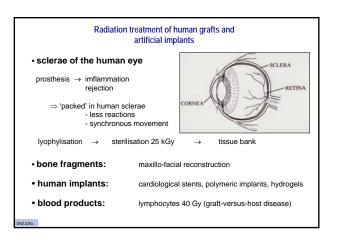


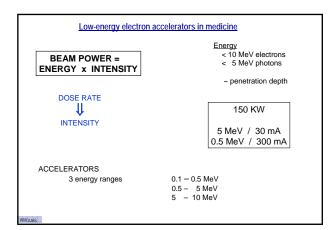


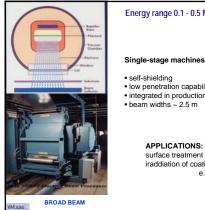




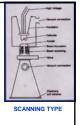








Energy range 0.1 - 0.5 MeV



low penetration capability integrated in production line beam widths ~ 2.5 m

APPLICATIONS:

APPLICATIONS. surface treatment iraddiation of coatings, adhesives, inks e.g. thin film packaging printing industry

